

CS III Dr. Vasile TIRON - Lista de lucrări științifice

1. **V. Tiron**, C. Vitelaru, M. Solomon, F. M. Tufescu, G. Popa, *"Transitory phenomena in pulsed reactive magnetron discharge"*, Journal of Optoelectronics and Advanced Materials 8(1) (2006) 66-70.

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